

**PATENT APPLICATION**  
**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of Docket No: Q92261

Massimo TORMEN, et al.

Appln. No.: 10/562,014 Group Art Unit: 1791

Confirmation No.: 2979 Examiner: Larry W. Thrower

Filed: March 14, 2006

For: A NANO IMPRESSION LITHOGRAPHIC PROCESS WHICH INVOLVES THE USE  
OF A DIE HAVING A REGION ABLE TO GENERATE HEAT

**RESPONSE TO NON-COMPLIANT AMENDMENT UNDER 37 C.F.R. § 1.111**

**MAIL STOP AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated July 2, 2009, please amend the above-identified application as follows on the accompanying pages.

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